

ABSTRACT OF THE DISCLOSURE

A transparent conductive layered structure which has the functions of preventing electrostatic charging or shielding an electric field, and preventing reflection, the two-layered film of which has an excellent scratch strength, and with which a reduction in production cost is expected and a method of producing the same, and a transparent coat layer forming coating liquid used in the method of producing the same, and a display device to which the transparent conductive layered structure is applied, are provided. A transparent conductive layered structure of the present invention, comprises a transparent substrate and a transparent two-layered film being composed of a and a transparent coat layer being formed in succession on the transparent substrate, wherein the transparent conductive layer comprises, as its main components, conductive microparticles having a mean particle diameter of 1 to 100 nm and a binder matrix of silicon oxide, and wherein the transparent coat layer comprises, as its main component, a binder matrix of silicon oxide including one or more types of alkyl groups selected from long chain alkyl groups containing 7 to 30 carbon atoms.